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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/635,892	08/05/2003	Jihperng Leu	884.657US2	1599	
21186	7590 07/12/200	6	EXAMINER		
SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A. P.O. BOX 2938			GURLEY, L	GURLEY, LYNNE ANN	
	MINNEAPOLIS, MN 55402		ART UNIT	PAPER NUMBER	
	,		2812		

DATE MAILED: 07/12/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Summary	10/635,892	LEU ET AL.				
Office Action Summary	Examiner	Art Unit				
	Lynne A. Gurley	2812				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim fill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 24 Ap	<u>oril 2006</u> .					
2a) ☐ This action is FINAL . 2b) ☒ This	This action is FINAL . 2b)⊠ This action is non-final.					
3) Since this application is in condition for allowar	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	i3 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) <u>1-17</u> is/are pending in the application.						
, , , , , , , , , , , , , , , , , , , ,	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-17</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examine	r.					
10) The drawing(s) filed on is/are: a) acce		Examiner.				
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	9 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).				
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a))-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the prior	•	ed in this National Stage				
application from the International Bureau	1 11					
* See the attached detailed Office action for a list of	of the certified copies not receive	LYNNE A. GURLEY				
		LYNNE A. GURLEY				
	PRI	MARY PATENT EXAMINER				
Attachment(s)		TC 2800, AU 2812				
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date						
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) 		ate ratent Application (PTO-152)				
Paper No(s)/Mail Date	6) Other:					

DETAILED ACTION

This Office Action is in response to the RCE filed 4/24/06.

Currently, claims 1-17 are pending.

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 4/24/06 has been entered.

Specification

1. The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

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3. Claims 1, 3 and 7 are rejected under 35 U.S.C. 102(e) as being anticipated by Ng (US 5.994.217, dated 11/30/99).

Ng shows the method as claimed in figure 6 and corresponding text, as forming a first interlayer dielectric (ILD) layer 20 above a substrate 10; forming a recess in the first ILD layer; filling the first recess with a first interconnect 32; forming a conductive first diffusion barrier layer (layer 34, which directly contacts the layer 32, or ITiN layer 28) above and on the first interconnect; forming an upper ILD layer 40 above the first conductive diffusion barrier layer 34; forming an upper recess in the upper ILD layer to optionally expose the first conductive diffusion barrier layer 34 (before filling with barrier 44); forming an upper interconnect 48 in the upper recess; and forming a conductive upper diffusion barrier layer 50 above and on the upper interconnect.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.

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3. Resolving the level of ordinary skill in the pertinent art.

4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

6. Claims 2, 4-6, 8-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ng (US 5,994,217, dated 11/30/99).

Ng shows the method substantially as claimed and as described in the preceding paragraph. Additionally, Ng uses BPTEOS oxide or BPSG.

Ng lacks anticipation only in not teaching that an organic ILD layer may be used and that the barrier layers may be formed by electroless plating.

It would have been obvious to one of ordinary skill in the art to have used an organic ILD layer or a combination of inorganic and organic ILD layers, in the method of Ng, with the motivation that the organic dielectric layer will reduce the dielectric constant and the capacitance between interconnect devices and allow a custom and efficient alteration of the capacitance to suit the performance needs of the device. Additionally, it would have been obvious to one of ordinary skill in the art to have formed the barrier layers by electroless plating, in the method of Ng, with the motivation that electroless plating is a conventional alternative formation process for metal layers, which would yield comparable if not the same results in the device. Also, Ng suggests that the metal layers may be formed by other metal processes (col. 3, lines 65-67; column 4, line 1).

Response to Arguments

7. Applicant's arguments filed 4/24/06 have been fully considered but they are not persuasive. In response to Applicant's remarks, 28, is not the only barrier layer present in the

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structure. Even though layers 34 and 50 are disclosed as ARC layers, they also perform the function of physical barrier layers. They are made of the same material as a conventional barrier

layer. Although it is difficult to determine if 28 is on the recessed part of 32, layer 34 still meets

the claimed limitation.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Lynne A. Gurley whose telephone number is 571-272-1670. The

examiner can normally be reached on M-F 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Lynne A. Gurley

Primary Patent Examiner

TC 2800, Art Unit 2812

LAG

July 10, 2006